

U.S. Department of Commerce, Patent and Trademark Office		Docket No.	Serial No.
		AM-1622.D1	unknown
LIST OF RELEVANT ART CITED BY APPLICANT		Applicant	
(Use several sheets if necessary)		Hong Shih et al.	
		Filing Date	Group
		January 21, 2000	unknown

S. PTO  
09/489356  
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## U.S. Patent Documents

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						

## Foreign Patent Documents

## Translation

		Document Number	Date	Country	Class	Subclass	Yes	No
	AH							
	AJ							
	AK							
	AL							
	AM							
	AN							

## OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

<i>PK</i>	AO	Shaffer, "Engineering Properties of Carbides," <i>Engineered Materials Handbook</i> , vol. 4, "Ceramics and Glasses" (Materials Information Society, 1991), pp. 804-807, 843, 844
<i>PK</i>	AP	Linke et al., "Behavior of Boron Doped Graphites, Plasma Sprayed Boron Carbides and a-C/B:H as Plasma Facing Material," <i>J. Fusion Technology</i>
	AQ	
	AR	

Examiner *Judy Bagn* Date Considered *January 20, 2000*

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.